

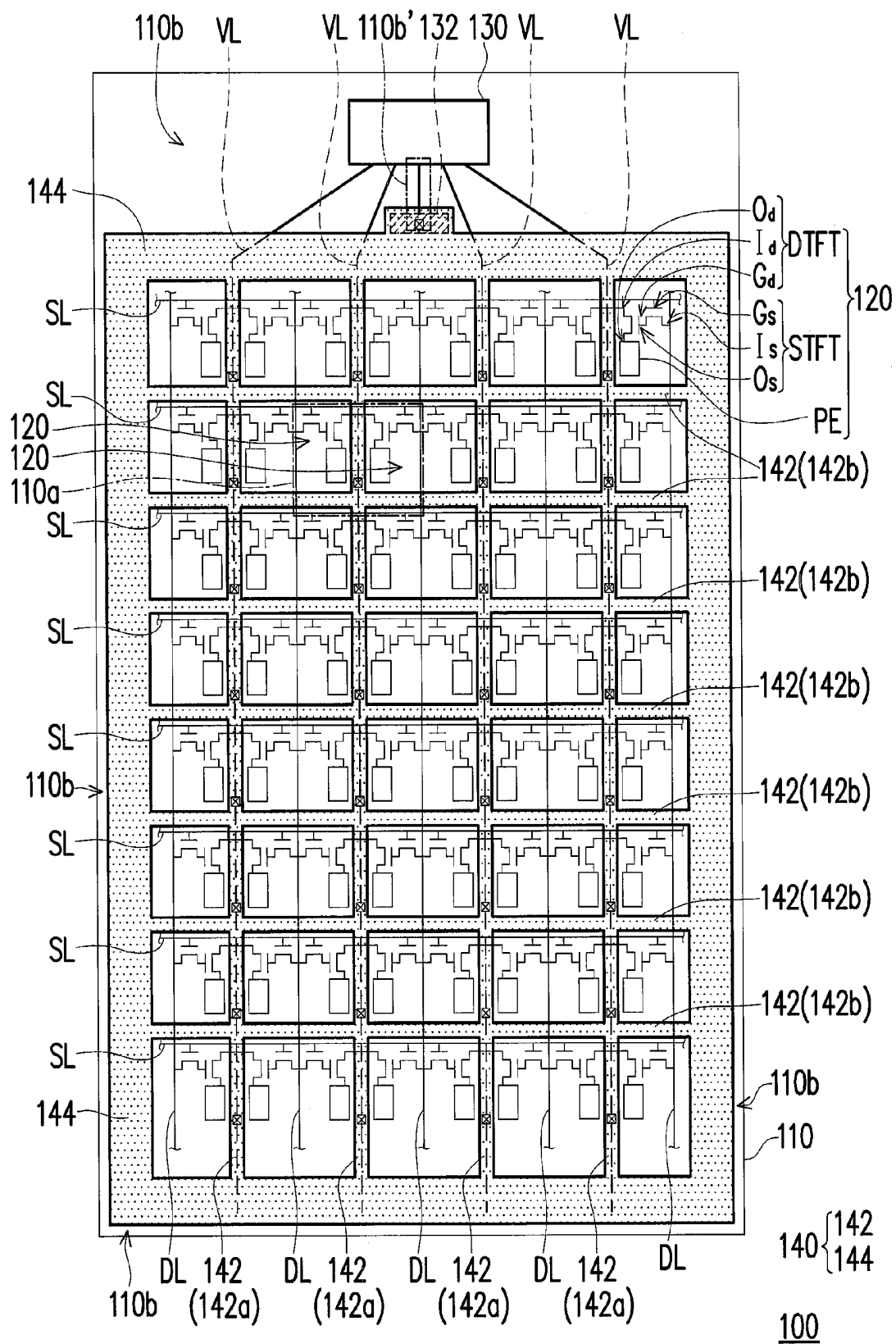


FIG. 1

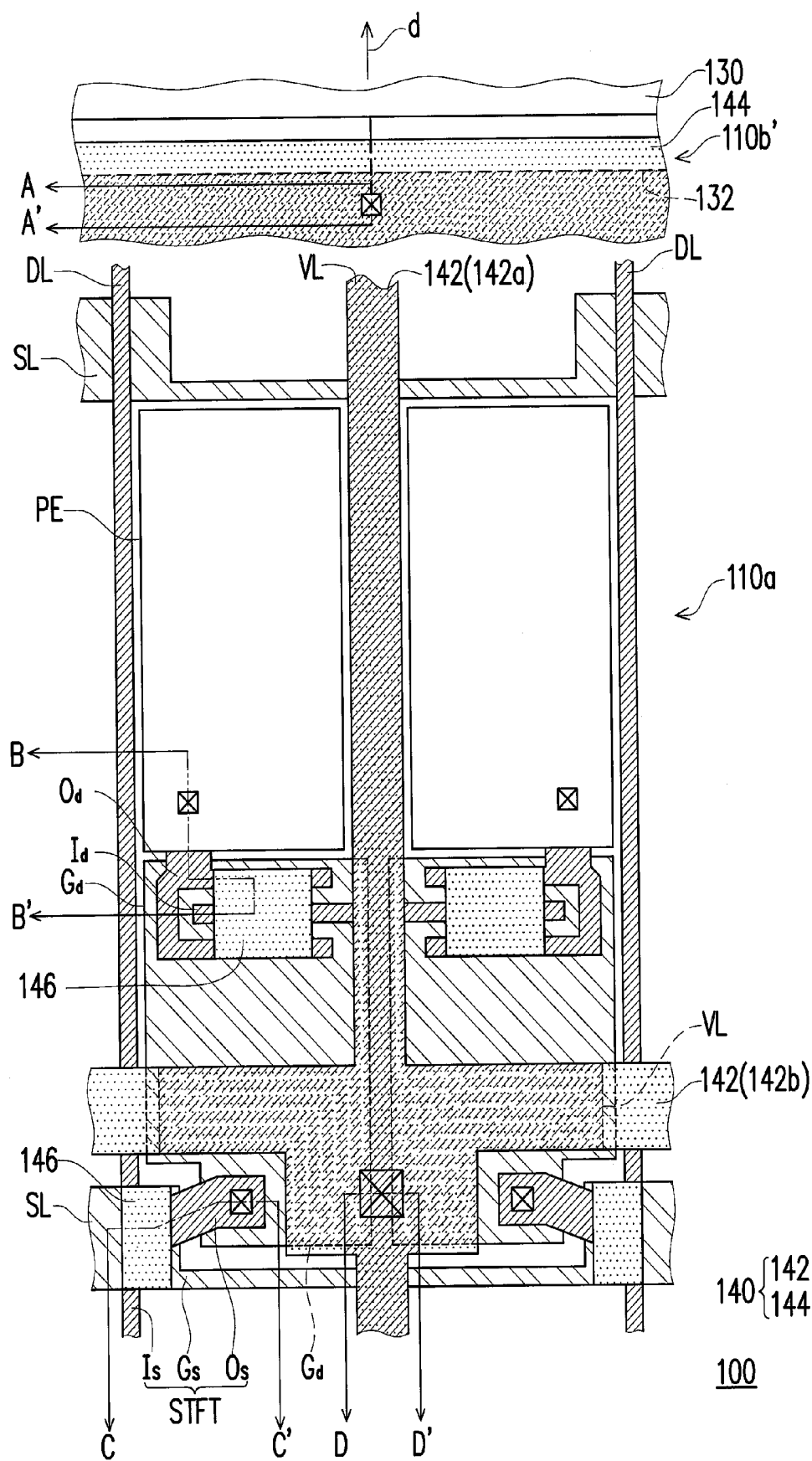


FIG. 2

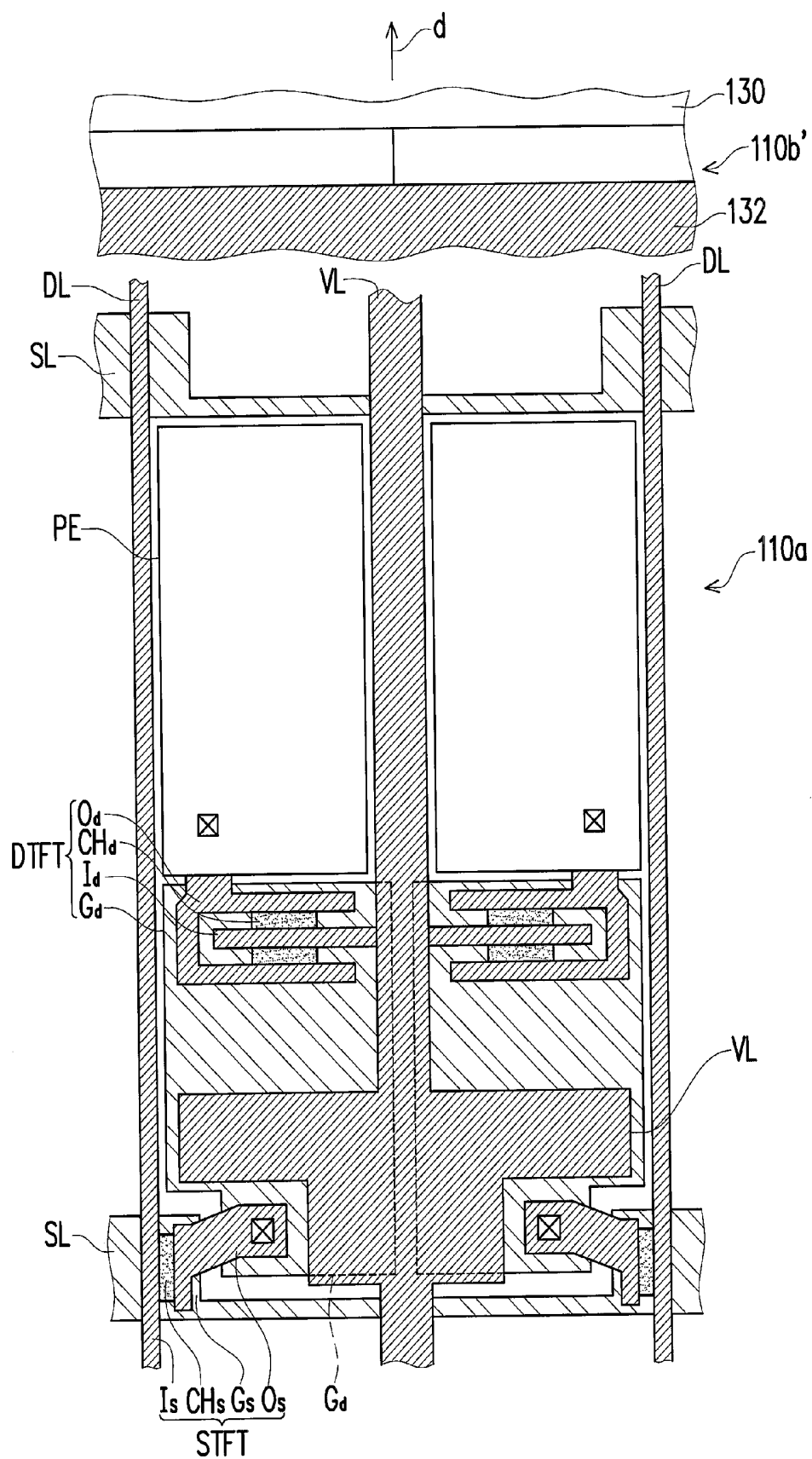


FIG. 3

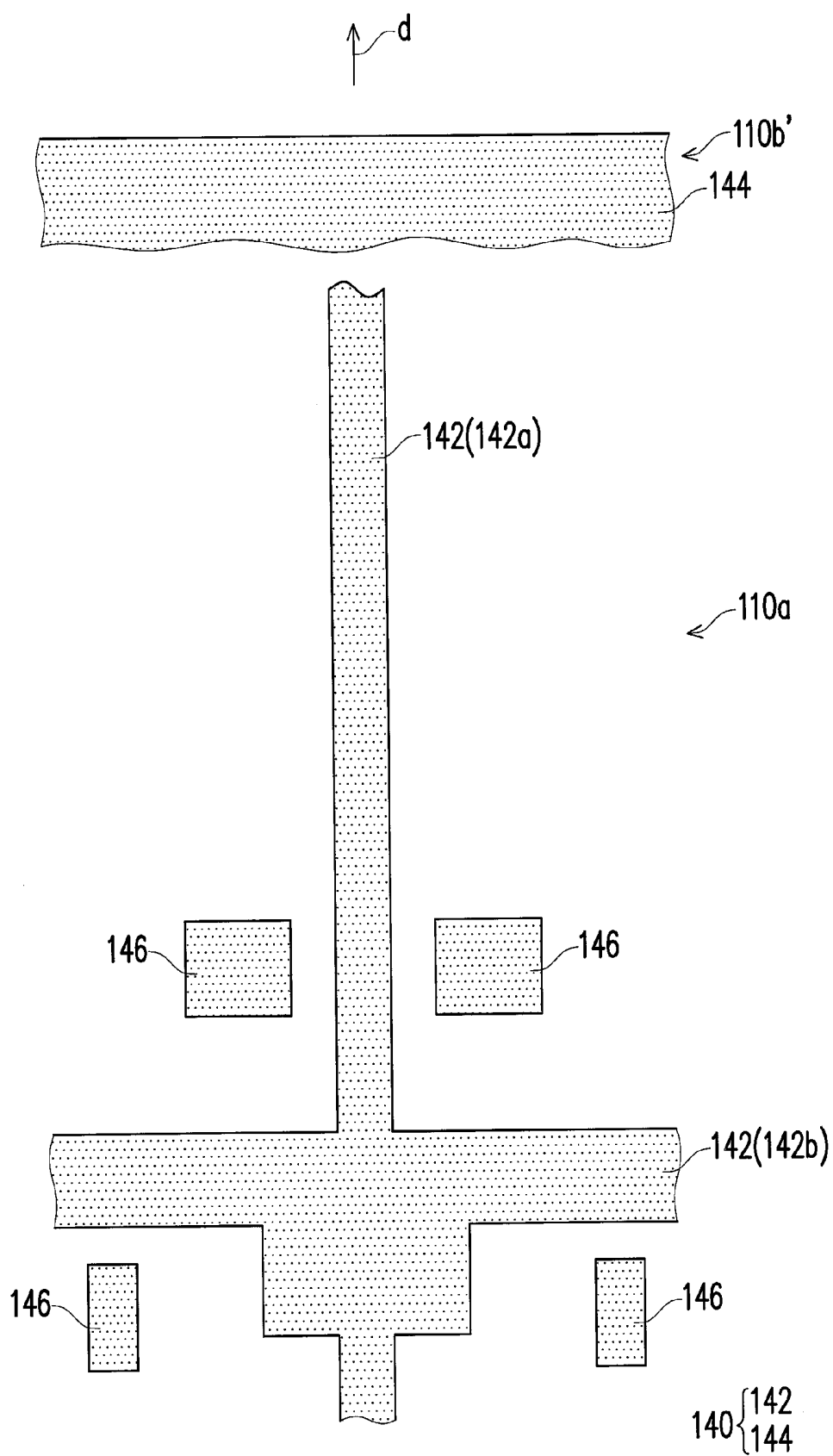


FIG. 4

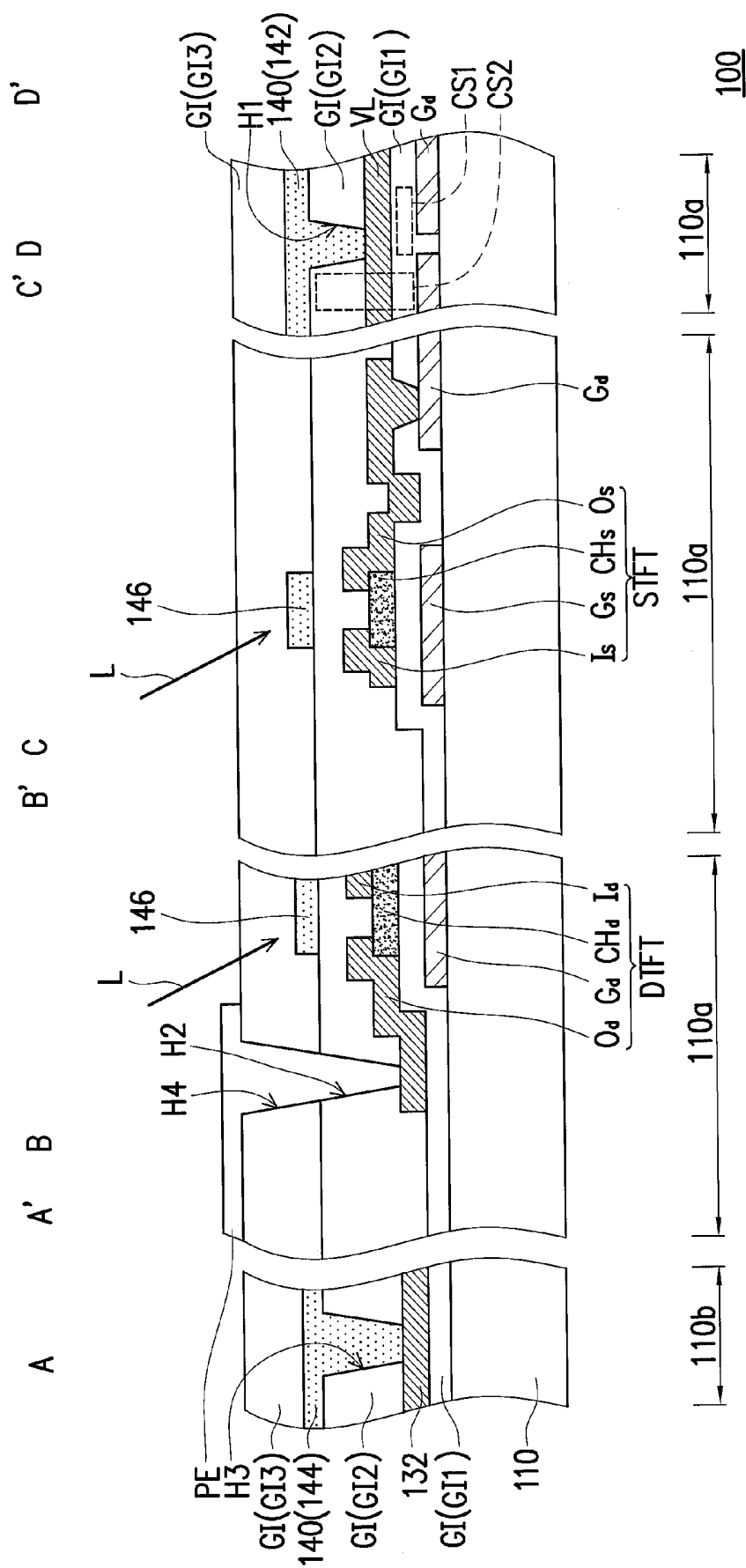


FIG. 5

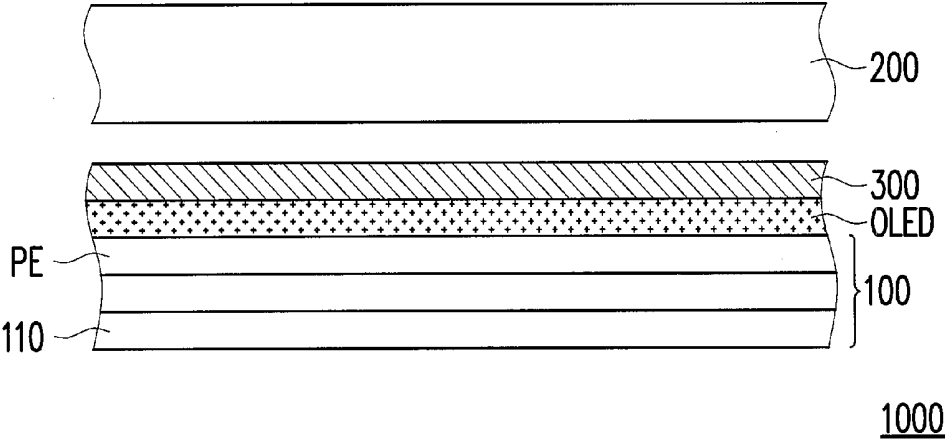


FIG. 6

FIG. 7

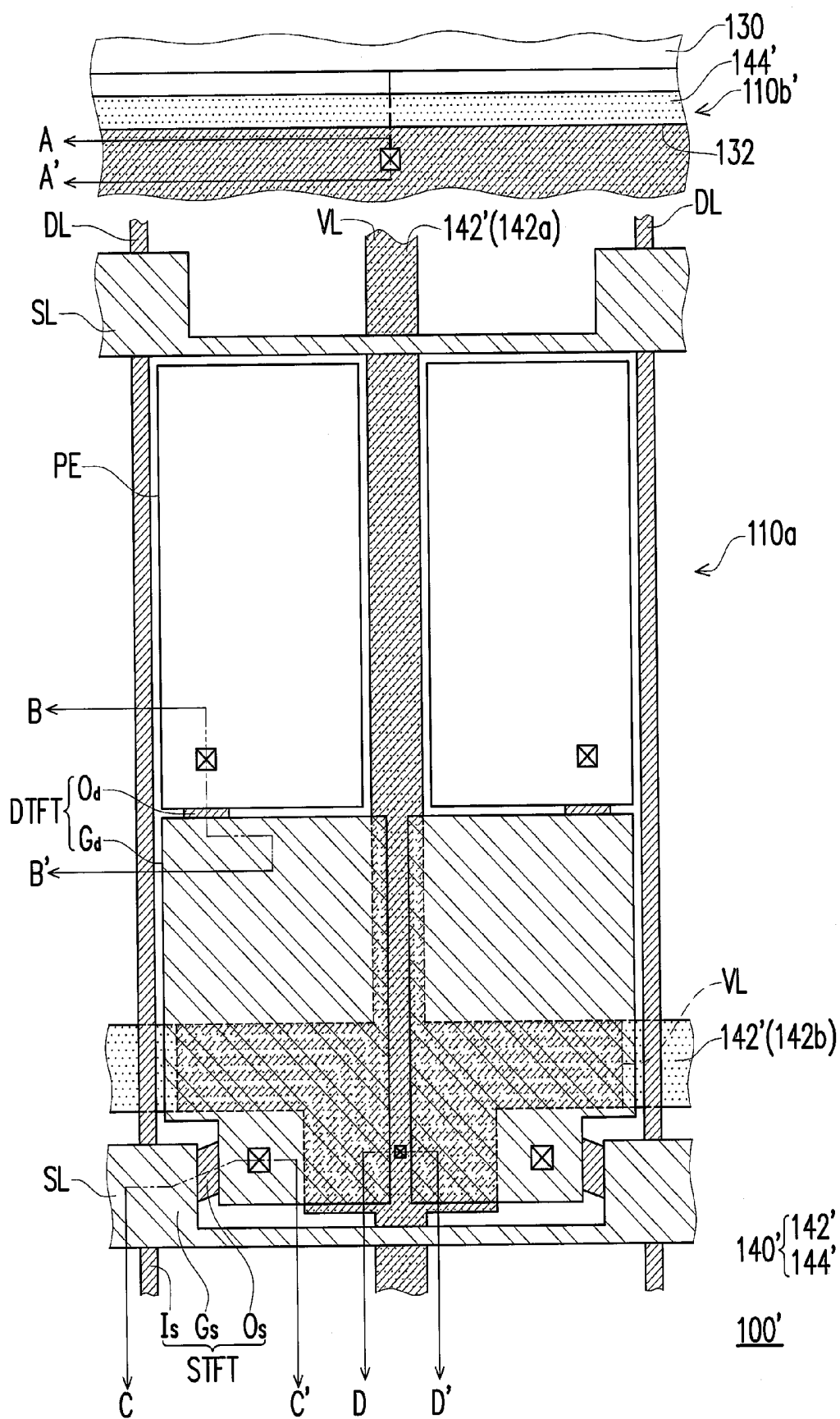


FIG. 8

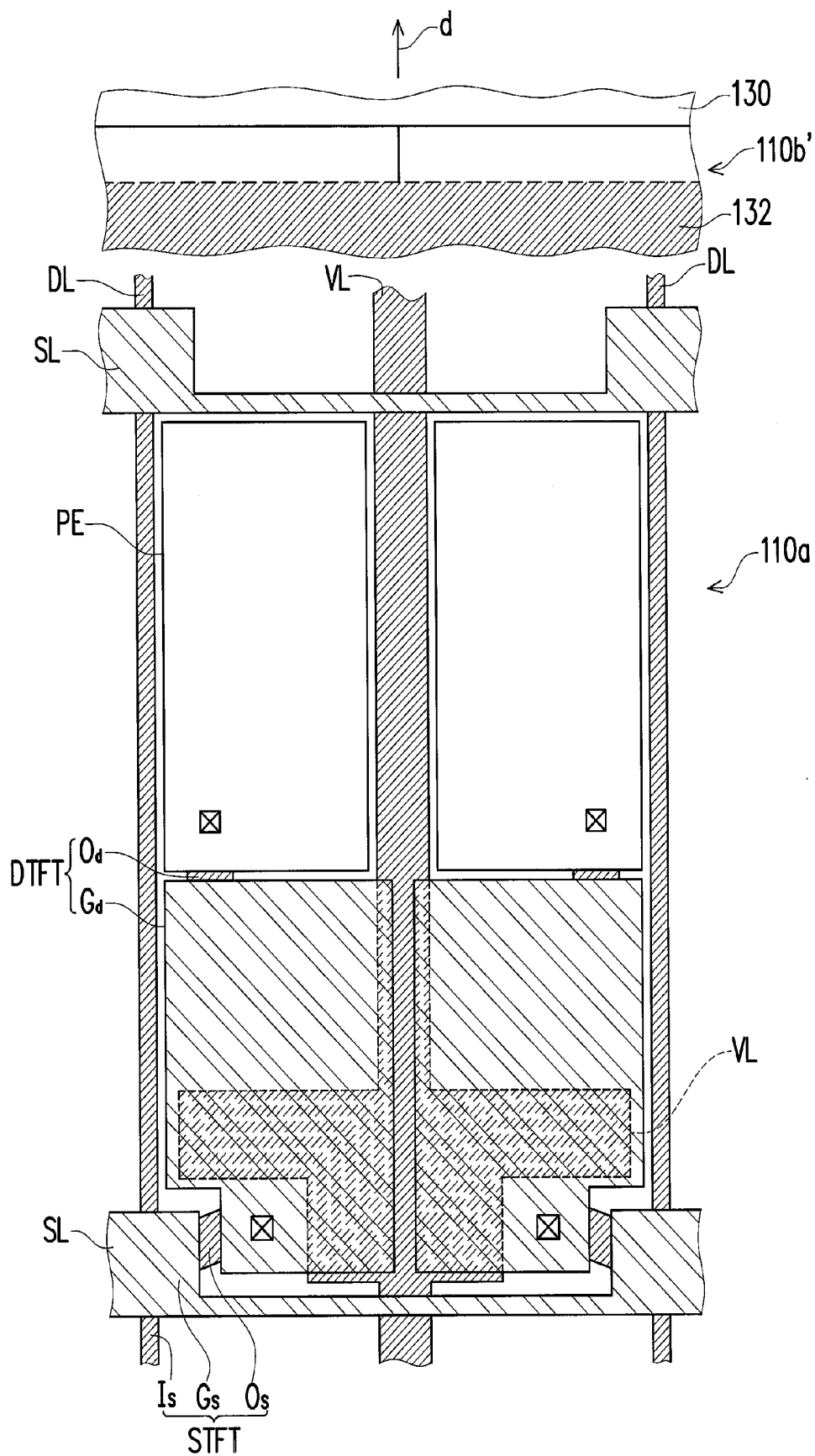


FIG. 9

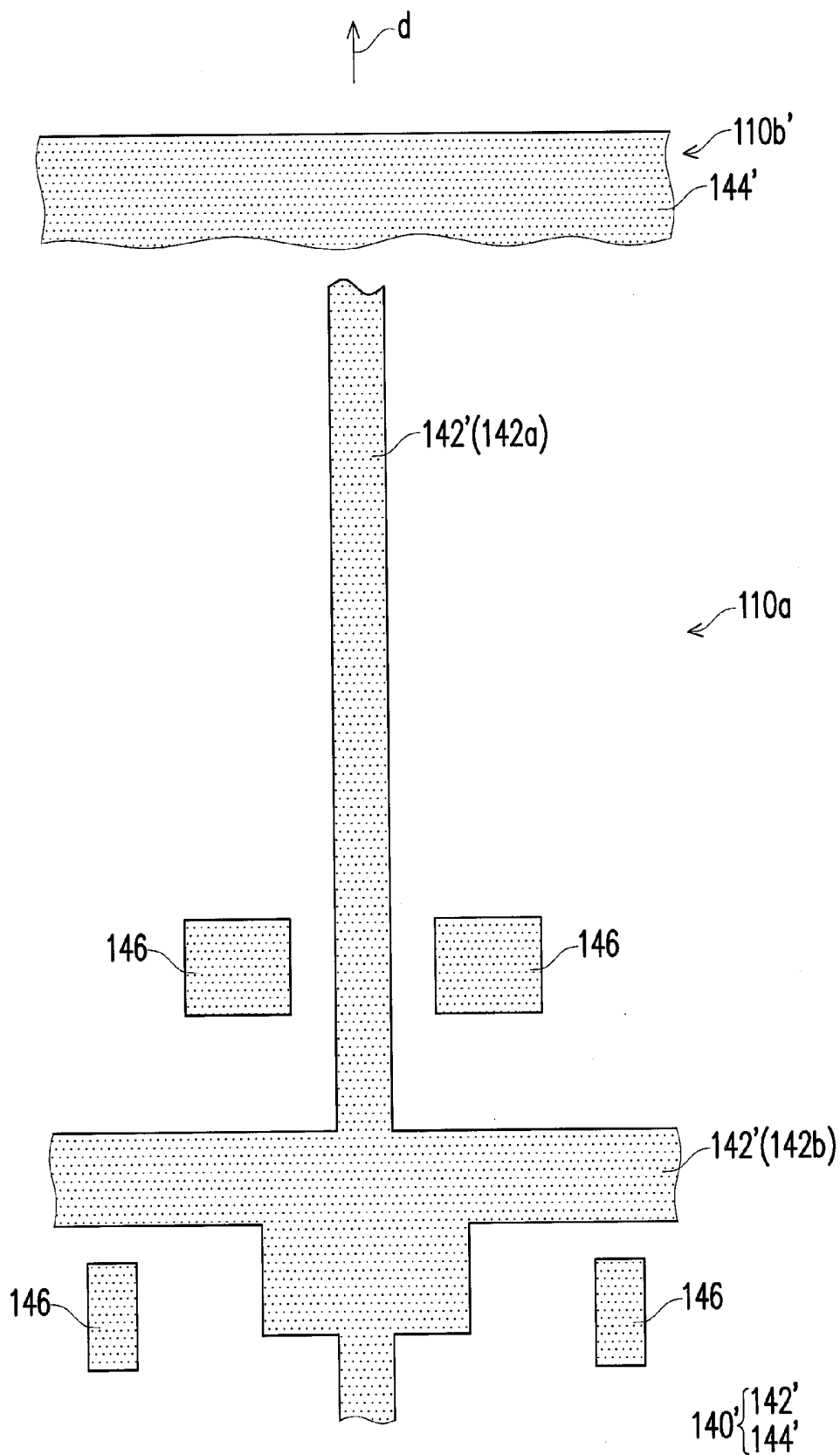
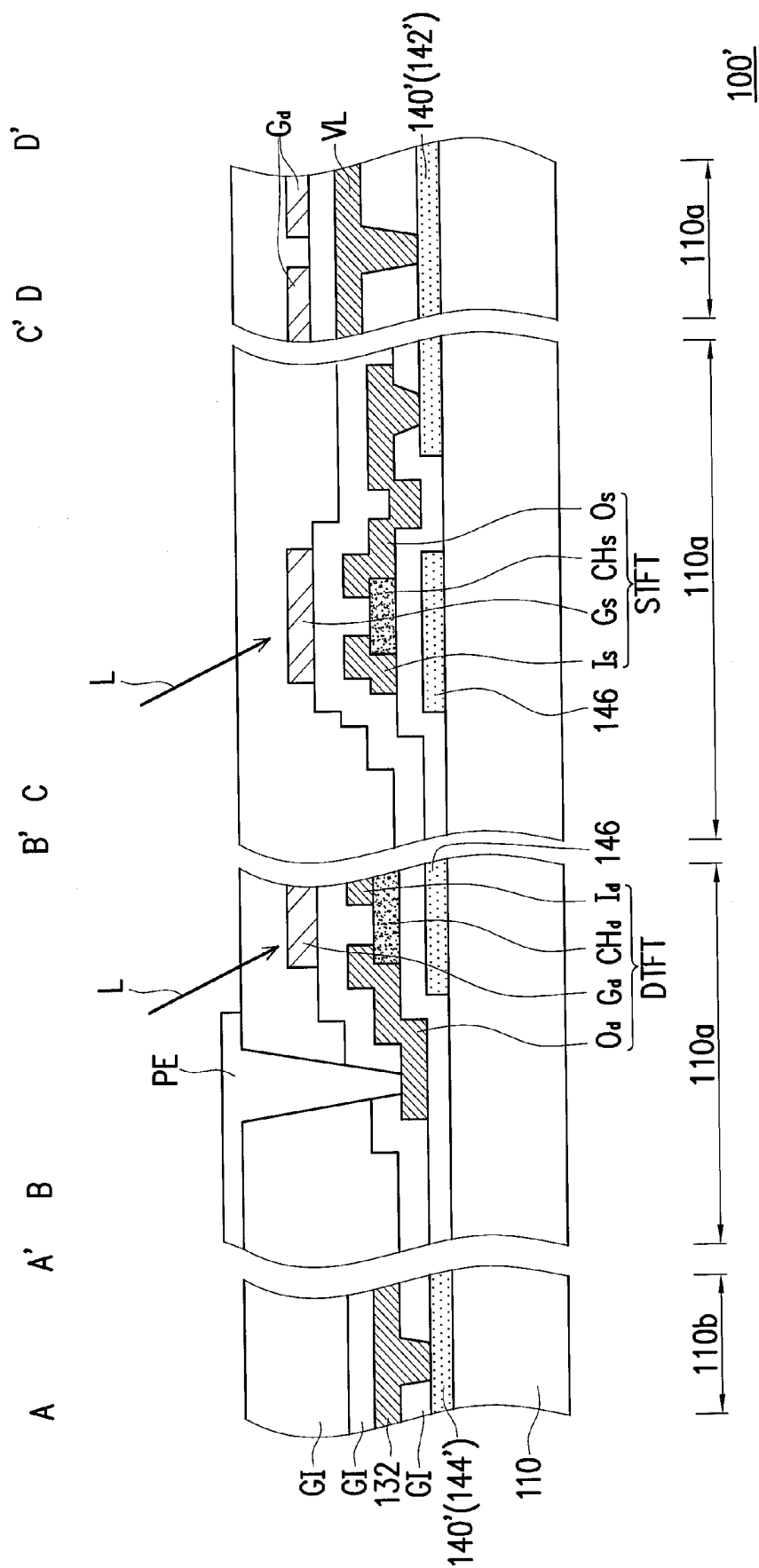


FIG. 10



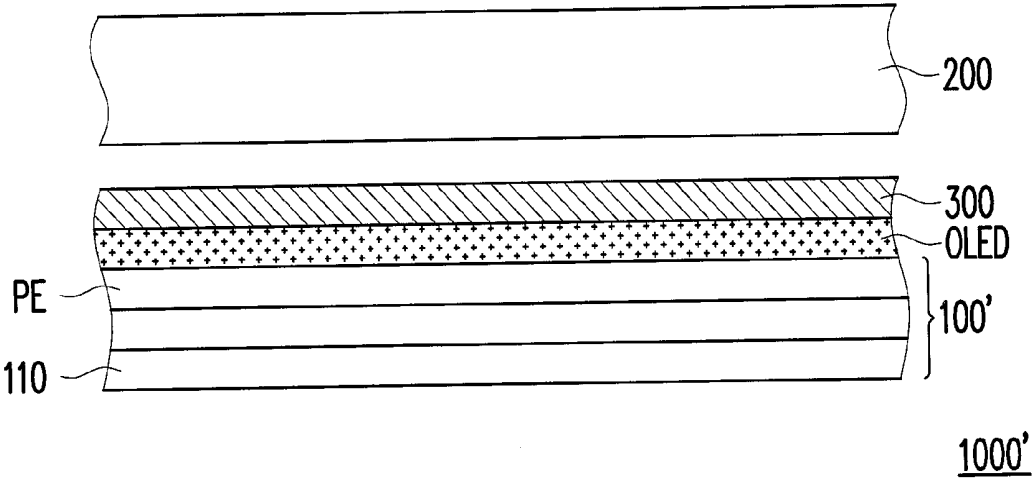


FIG. 12

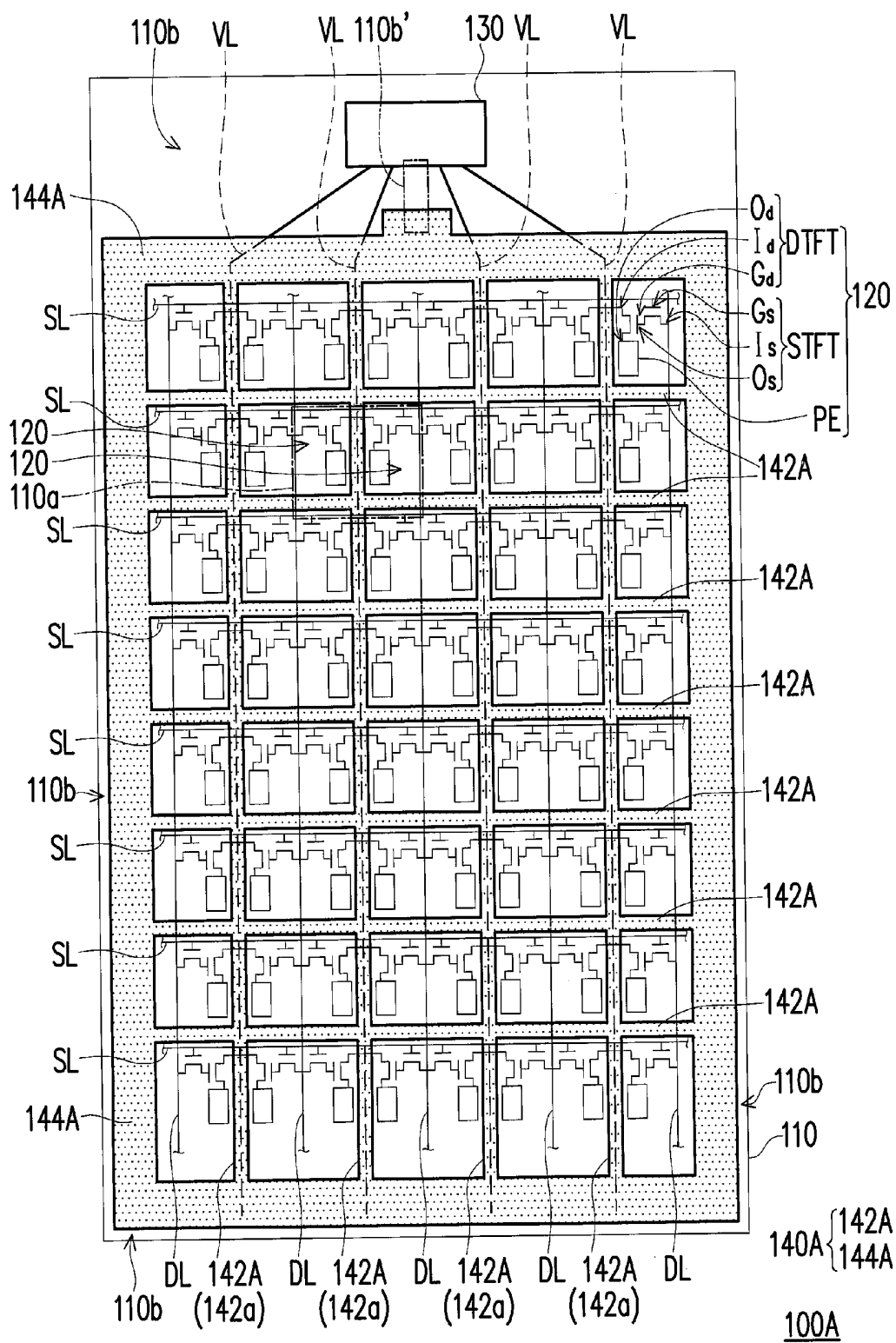


FIG. 13

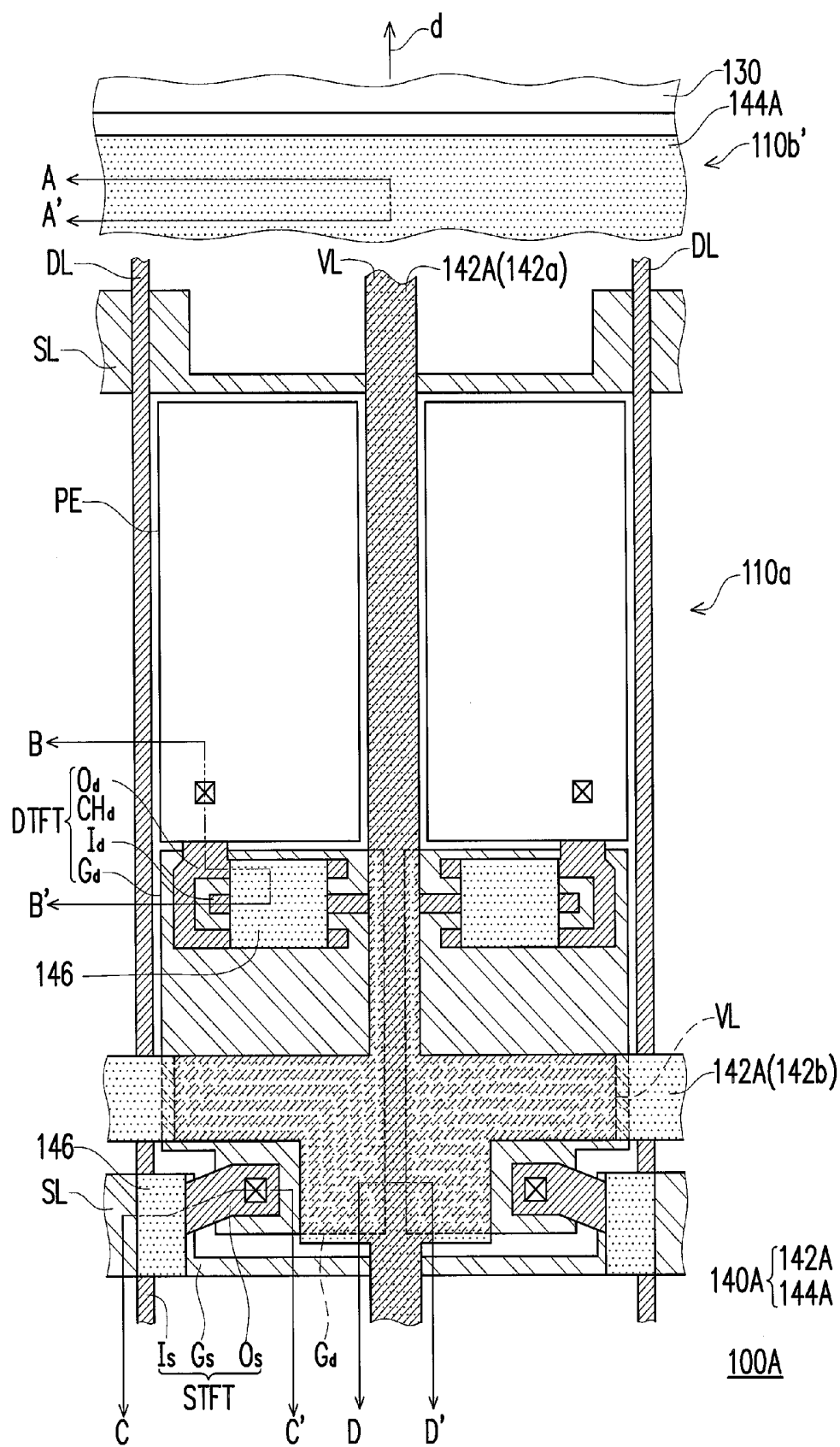


FIG. 14

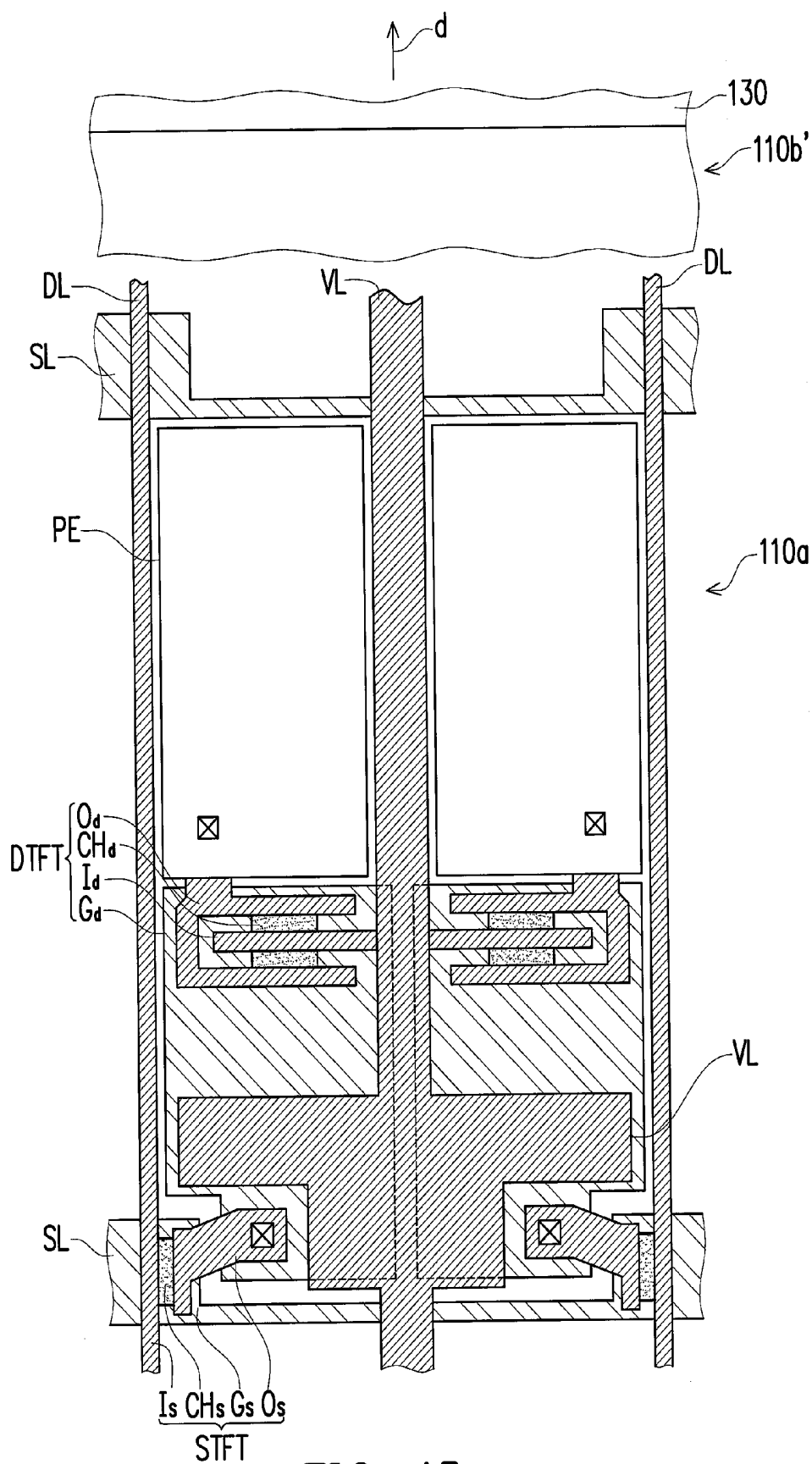


FIG. 15

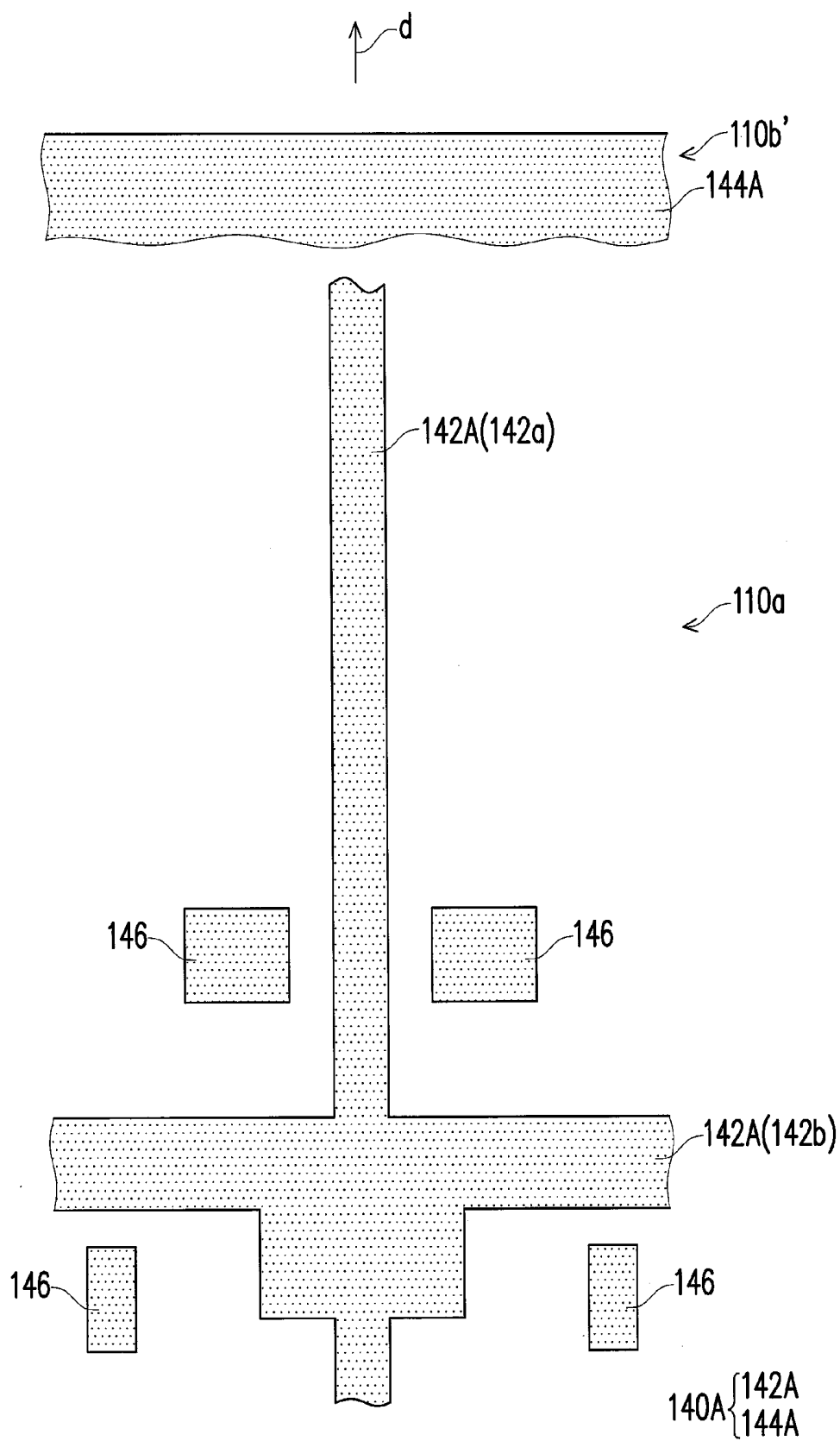


FIG. 16

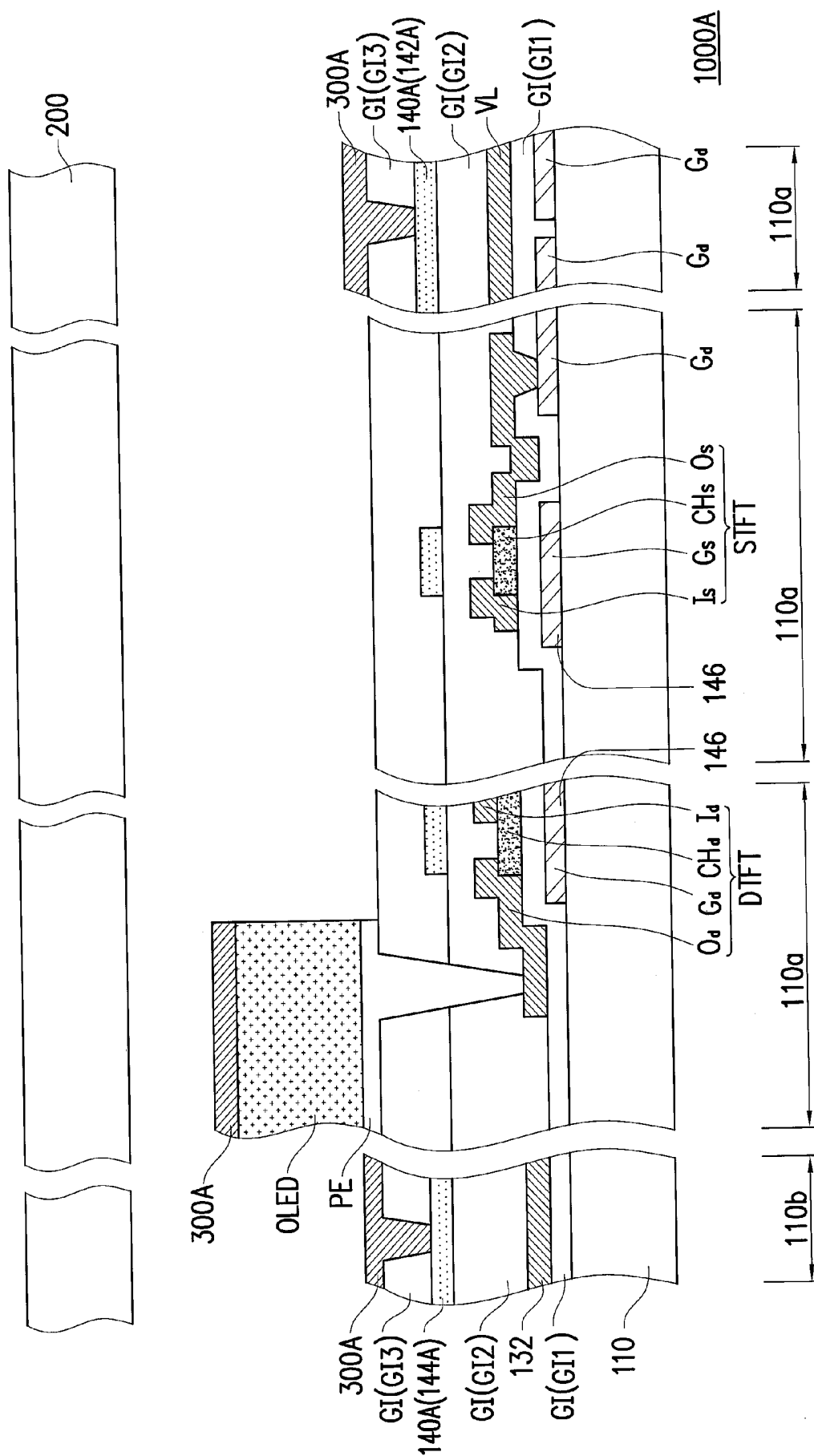


FIG. 18

PIXEL ARRAY SUBSTRATE AND ORGANIC LIGHT-EMITTING DIODE DISPLAY

CROSS-REFERENCE TO RELATED APPLICATION

[0001] This application claims the priority benefit of Taiwan application serial no. 102140462, filed on Nov. 7, 2013. The entirety of the above-mentioned patent application is hereby incorporated by reference herein and made a part of this specification.

BACKGROUND OF THE INVENTION

[0002] 1. Field of the Invention

[0003] The invention relates to a pixel array substrate and a display, and more particularly to a pixel array substrate applicable to an organic light-emitting diode (OLED) display and an OLED display.

[0004] 2. Description of Related Art

[0005] At present, displays are categorized into plasma displays, liquid crystal displays (LCD), inorganic electroluminescent displays, organic light-emitting diode (OLED) displays, field emission displays (FED), electro-chromic displays, and so forth. Compared with other types of displays, the OLED display has potential to become the mainstream in the next generation, for it has the advantages of self-luminescence, no viewing angle dependence, low power consumption, wide range of working temperature, fast response speed, full-color display, etc.

[0006] A conventional OLED display includes a plurality of pixel units distributed onto a substrate. Each of the pixel units includes a switch transistor, a driver transistor electrically coupled to the switch transistor, and a pixel electrode electrically coupled to the driver transistor. A constant voltage line transmits a constant voltage to an input electrode of the driver transistor of each pixel unit, such that the driver transistor is allowed to work in an amplification region. When the driver transistor stably works in the amplification region, the driver transistor is able to provide constant current to an OLED layer, and thereby each pixel unit is able to display images with proper brightness.

[0007] However, the distances from the pixel units distributed onto the substrate to a constant voltage source are inconsistent, thus leading to the difference in resistances between the input electrodes of the driver transistors and the constant voltage source. In this case, the constant voltage respectively transmitted to the input electrodes of the driver transistors may vary, and thereby the OLED display is not able to display images with favorable display quality.

[0008] From another perspective, in the conventional OLED display, a common electrode layer and a control electrode of the driver transistor may together constitute a pixel storage capacitor. Due to the excessively long distance between the common electrode layer and the control electrode of the driver transistor, the pixel storage capacitance is low, which poses a negative impact on the display effects of the OLED display.

SUMMARY OF THE INVENTION

[0009] The invention is directed to an organic light-emitting diode (OLED) display and a pixel array substrate capable of lessening the difference in resistances between input electrodes of driver transistors and a constant voltage source and further guaranteeing the favorable display capacity.

[0010] The invention is further directed to another OLED display capable of increasing pixel storage capacitance and further achieving satisfactory display effects.

[0011] In an embodiment of the invention, a pixel array substrate that includes a first substrate, a plurality of pixel units, a plurality of data lines, a plurality of scan lines, a plurality of constant voltage lines, a constant voltage source, a constant voltage pad, and a conductive pattern is provided. The first substrate has a plurality of pixel regions arranged in an array and a peripheral region surrounding the pixel regions. The pixel units are located in the pixel regions. Each of the pixel units includes a switch transistor, a driver transistor, and a pixel electrode. The switch transistor has an input electrode, a control electrode, and an output electrode; the driver transistor has an input electrode, a control electrode, and an output electrode. The output electrode of the switch transistor is electrically coupled to the control electrode of the driver transistor. The pixel electrode is electrically coupled to the output electrode of the driver transistor. The data lines are located on the first substrate and electrically coupled to the input electrodes of the switch transistors. The scan lines are located on the first substrate, interlaced with the data lines, and electrically coupled to the control electrodes of the switch transistors. The constant voltage lines are located on the first substrate and electrically coupled to the input electrodes of the driver transistors. The constant voltage source is located on the peripheral region of the first substrate and provides a constant voltage to the constant voltage lines. The constant voltage pad is located on the peripheral region of the first substrate and outputs the constant voltage. The conductive pattern is located on the first substrate. Here, the conductive pattern includes a plurality of conductive lines and a conductive frame. The conductive lines are interlaced with each other to form a net and located on the pixel regions of the first substrate. The conductive frame is located on the peripheral region of the first substrate. Here, the conductive frame surrounds and is electrically coupled to the conductive lines. The conductive frame is in electrical contact with the constant voltage pad within the peripheral region. Each of the pixel regions is defined by two adjacent scan lines and two adjacent data lines. Besides, each of the pixel regions covers at least one of the pixel units and a portion of one of the constant voltage lines. The covered portion of the one of the constant voltage lines completely within each of the pixel regions is located in the each of the pixel regions and is in electrical contact with one of the conductive lines of the conductive pattern.

[0012] In an embodiment of the invention, an OLED display that includes the aforesaid pixel array substrate, a second substrate opposite to the first substrate, an OLED layer located between the pixel electrodes and the second substrate, and a common electrode layer located between the second substrate and the OLED layer is provided.

[0013] In an embodiment of the invention, an OLED display that includes a pixel array substrate, a second substrate opposite to a first substrate, an OLED layer located between pixel electrodes and the second substrate, and a common electrode layer located between the second substrate and the OLED layer is provided. The pixel array substrate includes a first substrate, a plurality of pixel units, a plurality of data lines, a plurality of scan lines, a plurality of constant voltage lines, a constant voltage source, and a conductive pattern. The first substrate has a plurality of pixel regions arranged in an array and a peripheral region surrounding the pixel regions.

The pixel units are located in the pixel regions. Each of the pixel units includes a switch transistor, a driver transistor, and a pixel electrode. The switch transistor has an input electrode, a control electrode, and an output electrode; the driver transistor has an input electrode, a control electrode, and an output electrode. The output electrode of the switch transistor is electrically coupled to the control electrode of the driver transistor. The pixel electrode is electrically coupled to the output electrode of the driver transistor. The data lines are located on the first substrate and electrically coupled to the input electrodes of the switch transistors. The scan lines are located on the first substrate and electrically coupled to the control electrodes of the switch transistors. The constant voltage lines are located on the first substrate and electrically coupled to the input electrodes of the driver transistors. The constant voltage source is located on the peripheral region of the first substrate and provides a constant voltage to the constant voltage lines. The conductive pattern is located on the first substrate and overlapped with the control electrode of each of the driver transistors. The common electrode layer is overlapped with the control electrodes of the driver transistors. A film layer where the control electrodes of the driver transistors are located are between the first substrate and a film layer where the input electrodes of the driver transistors are located. The film layer where the input electrodes of the driver transistors are located are between a film layer where the conductive pattern is located and the film layer where the control electrodes of the driver transistors are located. The conductive pattern is in electrical contact with the common electrode layer.

[0014] According to an embodiment of the invention, the conductive lines of the conductive pattern and the constant voltage lines are overlapped.

[0015] According to an embodiment of the invention, the conductive lines are divided into a plurality of first conductive lines and a plurality of second conductive lines, the first conductive lines are parallel to extension directions of the constant voltage lines, the second conductive lines are interlaced with the first conductive lines, and the constant voltage lines cover the first conductive lines.

[0016] According to an embodiment of the invention, the second conductive lines are overlapped with the control electrodes of the driver transistors and the data lines.

[0017] According to an embodiment of the invention, the constant voltage lines is overlapped with the control electrode of the driver transistor of the pixel units, so as to constitute a first storage capacitor. The conductive line is overlapped with the control electrode of the driver transistor of the pixel units, so as to constitute a second storage capacitor. The first storage capacitor and the second storage capacitor are connected in parallel to constitute a pixel storage capacitor of the pixel units.

[0018] According to an embodiment of the invention, the conductive pattern is in a film layer different from film layers where the output electrodes of the driver transistors, the input electrodes of the driver transistors, the control electrodes of the driver transistors, and the pixel electrodes are located.

[0019] According to an embodiment of the invention, a film layer where the control electrodes of the driver transistors are located are between the first substrate and a film layer where the input electrodes of the driver transistors are located. The film layer where the input electrodes of the driver transistors

are located is between a film layer where the conductive pattern is located and the film layer where the control electrodes of the driver transistors are located.

[0020] According to an embodiment of the invention, a film layer where the conductive pattern is located is between the first substrate and a film layer where the input electrodes of the driver transistors are located. The film layer where the input electrodes of the driver transistors are located is between a film layer where the control electrodes of the driver transistors are located and the film layer where the conductive pattern is located.

[0021] According to an embodiment of the invention, the pixel array substrate further includes a plurality of light-shielding patterns. The light-shielding patterns respectively shield a plurality of channels of the switch transistors and a plurality of channels of the driver transistors.

[0022] According to an embodiment of the invention, the common electrode layer is overlapped with the control electrode of the driver transistor of the pixel unit to constitute a first storage capacitor. A portion of the conductive lines is overlapped with the control electrode of the driver transistor of the pixel unit to constitute a second storage capacitor. The first storage capacitor and the second storage capacitor are connected in parallel to constitute a pixel storage capacitor of the one of the pixel units.

[0023] According to an embodiment of the invention, the conductive pattern includes a plurality of conductive lines and a conductive frame. The conductive lines are interlaced with each other to form a net and located on the pixel regions of the first substrate. The conductive frame is located on the peripheral region of the first substrate. Here, the conductive frame surrounds and is electrically coupled to the conductive lines.

[0024] As discussed above, in the OLED display and the pixel array substrate of the OLED display described in an embodiment of the invention, the net-shaped conductive pattern lessens the difference in resistances between the constant voltage source and the input electrodes of the driver transistors distributed onto the first substrate, and thereby the constant voltage respectively transmitted into the input electrode of each driver transistor does not vary significantly. Thereby, the conventional issue of unfavorable display quality caused by the significant difference in resistances between the input electrodes of the driver transistors and the constant voltage source can be better resolved.

[0025] Besides, in the OLED display provided in another embodiment of the invention, through the conductive pattern that is in electrical contact with the common electrode and is overlapped with the control electrode of each pixel unit, the pixel storage capacitance of each pixel unit may increase, and thus the OLED display is able to accomplish favorable display effects.

[0026] To make the above features and advantages of the invention more comprehensible, several embodiments accompanied with drawings are described in detail as follows.

BRIEF DESCRIPTION OF THE DRAWINGS

[0027] The accompanying drawings are included to provide further understanding, and are incorporated in and constitute a part of this specification. The drawings illustrate exemplary embodiments and, together with the description, serve to explain the principles of the invention.

[0028] FIG. 1 is a schematic diagram illustrating a pixel array substrate according to a first embodiment of the invention.

[0029] FIG. 2 is a schematic diagram illustrating one of the pixel regions and a portion of the peripheral region in the pixel array substrate according to the first embodiment of the invention.

[0030] FIG. 3 illustrates film layers other than the film layer where the conductive pattern depicted in FIG. 2 is located.

[0031] FIG. 4 illustrates the film layer where the conductive pattern depicted in FIG. 2 is located.

[0032] FIG. 5 is a schematic cross-sectional diagram illustrating the pixel array substrate depicted in FIG. 2 along sectional lines A-A', B-B', C-C', and D-D' according to the first embodiment of the invention.

[0033] FIG. 6 is a schematic cross-sectional diagram illustrating an organic light-emitting diode (OLED) display according to the first embodiment of the invention.

[0034] FIG. 7 is a schematic diagram illustrating a pixel array substrate according to a second embodiment of the invention.

[0035] FIG. 8 is a schematic diagram illustrating one of the pixel regions and a portion of the peripheral region in the pixel array substrate according to the second embodiment of the invention.

[0036] FIG. 9 illustrates film layers other than the film layer where the conductive pattern depicted in FIG. 8 is located.

[0037] FIG. 10 illustrates the film layer where the conductive pattern depicted in FIG. 8 is located.

[0038] FIG. 11 is a schematic cross-sectional diagram illustrating the pixel array substrate depicted in FIG. 8 along sectional lines A-A', B-B', C-C', and D-D' according to the second embodiment of the invention.

[0039] FIG. 12 is a schematic cross-sectional diagram illustrating an OLED display according to the second embodiment of the invention.

[0040] FIG. 13 is a schematic diagram illustrating a pixel array substrate according to a third embodiment of the invention.

[0041] FIG. 14 is a schematic diagram illustrating one of the pixel regions and a portion of the peripheral region in the pixel array substrate according to the third embodiment of the invention.

[0042] FIG. 15 illustrates film layers other than the film layer where the conductive pattern depicted in FIG. 14 is located.

[0043] FIG. 16 illustrates the film layer where the conductive pattern depicted in FIG. 14 is located.

[0044] FIG. 17 is a schematic cross-sectional diagram illustrating the pixel array substrate depicted in FIG. 14 along sectional lines A-A', B-B', C-C', and D-D' according to the third embodiment of the invention.

[0045] FIG. 18 is a schematic cross-sectional diagram illustrating an OLED display according to the third embodiment of the invention.

substrate 110, a plurality of pixel units 120, a plurality of data lines DL, a plurality of scan lines SL interlaced with the data lines DL, a plurality of constant voltage lines VL, a constant voltage source 130, and a constant voltage pad 132. The first substrate 110 has a plurality of pixel regions 110a arranged in an array and a peripheral region 110b surrounding the pixel regions 110a. Each of the pixel regions 110a is defined by two adjacent scan lines SL and two adjacent data lines DL. That is, each of the pixel regions 110a includes an area surrounded by two adjacent scan lines SL and two adjacent data lines DL, a portion of the two scan lines SL adjacent to the area, and a portion of the two data lines DL adjacent to the area. The pixel units 120 are located in the pixel regions 110a. To be specific, each of the pixel regions 110a includes at least one of the pixel units 120. In the present embodiment, each of the pixel regions 110a may include two of the pixel units 120. However, the invention is not limited thereto, and each of the pixel regions 110a may merely include one pixel unit 110a according to another embodiment.

[0047] Each of the pixel units 120 includes a switch transistor STFT, a driver transistor DTFT, and a pixel electrode PE. The switch transistor STFT has an input electrode Is, a control electrode Gs, and an output electrode Os; the driver transistor DTFT has an input electrode Id, a control electrode Gd, and an output electrode Od. In each of the pixel units 120, the output electrode Os of the switch transistor STFT is electrically coupled to the control electrode Gd of the driver transistor DTFT, and the pixel electrode PE is electrically coupled to the output electrode Od of the driver transistor DTFT. The data lines DL are located on the first substrate 110 and electrically coupled to the input electrodes Is of the switch transistors STFT. The scan lines SL are located on the first substrate 110 and electrically coupled to the control electrodes Gs of the switch transistors STFT. The constant voltage lines VL are electrically coupled to the input electrodes Id of the driver transistors DTFT. In the present embodiment, extension directions of the data lines DL may be perpendicular to extension directions of the scan lines SL, and extension directions of the constant voltage lines VL may be parallel to the extension directions of the data lines DL, for instance. However, the invention is not limited thereto, and the data lines DL, the scan lines SL, and the constant voltage lines VL may be arranged in another appropriate manner.

[0048] The constant voltage source 130 is located on the peripheral region 110b of the first substrate 110 and provides a constant voltage to the constant voltage lines VL. The constant voltage pad 132 is located on the peripheral region 110b of the first substrate 110 and outputs the constant voltage provided by the constant voltage source 130. In the present embodiment, the constant voltage pad 132 may be a conductive article separated from the constant voltage lines VL. However, the invention is not limited thereto, and the constant voltage pad 132 in another embodiment may refer to a portion of the constant voltage lines VL that is located in the peripheral region 110b and extended toward the constant voltage source 130.

[0049] The pixel array substrate 100 further includes a conductive pattern 140 located on the first substrate 110. The conductive pattern 140 includes a plurality of conductive lines 142 interlaced with each other to form a net and located on the pixel regions 110a and a conductive frame 144 located in the peripheral region 110b. The conductive frame 144 surrounds and is electrically coupled to the conductive lines 142. Particularly, the conductive frame 144 may be in elec-

DETAILED DESCRIPTION OF DISCLOSED EMBODIMENTS

First Embodiment

[0046] FIG. 1 is a schematic diagram illustrating a pixel array substrate according to a first embodiment of the invention. With reference to FIG. 1, according to the present embodiment, the pixel array substrate 100 includes a first

trical contact with all of the conductive lines **142** and has the same electrical potential as those of the conductive lines **142**. In the present embodiment, the conductive lines **142** and the conductive frame **144** may be located in the same film layer. However, the invention is not limited thereto.

[0050] It should not be mentioned that the conductive frame **144** is in electrical contact with the constant voltage pad **132** within the peripheral region **110b**, and a portion of at least one of the constant voltage lines VL completely within each of the pixel regions **110a** is located in each of the pixel regions **110a** and is in electrical contact with at least one of the conductive lines **142**. In the present embodiment, each of the pixel regions **110a** covers one of first conductive lines **142a** and one of second conductive lines **142b** which are interlaced with each other, and the covered portion of the at least one of the constant voltage lines VL completely within each of the pixel regions **110a** may be in electrical contact with the one of the first conductive lines **142a**, the one of the second conductive lines **142b**, or a combination thereof. As shown in FIG. 1, the covered portion of one of the constant voltage lines VL completely within each of the pixel regions **110a** is in electrical contact with one of the first conductive lines **142a**. However, the invention is not limited thereto, and the covered portion of one of the constant voltage lines VL completely within each of the pixel regions **110a** may also be in electrical contact with one of second conductive lines **142b** or simultaneously in electrical contact with the first and second conductive lines **142a** and **142b** according to other embodiments of the invention.

[0051] In view of said electrical connection, the net-shaped conductive pattern **140** is able to lessen the difference in resistances between the constant voltage source **130** and the input electrodes Id of the driver transistors DTFT distributed onto the first substrate **110**, and thereby the constant voltage respectively transmitted into the input electrode Id of each driver transistor DTFT does not vary significantly. Thereby, the conventional issue of unfavorable display quality caused by the significant difference in resistances between the input electrodes of the driver transistors and the constant voltage source can be better resolved.

[0052] FIG. 2 is a schematic diagram illustrating one of the pixel regions and a portion of the peripheral region in the pixel array substrate according to the first embodiment of the invention. The pixel region **110a** shown in FIG. 2 corresponds to the pixel region **110a** surrounded by dotted lines in FIG. 1, and the portion of the peripheral region **110b'** shown in FIG. 2 corresponds to the peripheral region **110b'** surrounded by dotted lines in FIG. 1. FIG. 3 illustrates film layers other than the film layer where the conductive pattern depicted in FIG. 2 is located. FIG. 4 illustrates the film layer where the conductive pattern depicted in FIG. 2 is located. Note that FIG. 1 serves to explain the electrical connection among the components in the pixel array substrate, while the detailed structures of these components in the pixel array substrate are shown in FIG. 2, FIG. 3, and FIG. 4. The structures of these components in the pixel array will be elaborated hereinafter with reference to FIG. 2, FIG. 3, and FIG. 4.

[0053] As shown in FIG. 2, FIG. 3, and FIG. 4, in the present embodiment, the conductive lines **142** of the conductive pattern **140** and the constant voltage lines VL are overlapped. Specifically, the conductive lines **142** are divided into a plurality of first conductive lines **142a** and a plurality of second conductive lines **142b**, the first conductive lines **142a** are parallel to extension directions d of the constant voltage

lines VL, and the second conductive lines **142b** are interlaced with the first conductive lines **142a**. The constant voltage lines VL cover the first conductive lines **142a**. The second conductive lines **142b** may be overlapped with the control electrodes Gd of the driver transistors DTFT and the data lines DL. In brief, the area occupied by the conductive pattern **140** is mostly overlapped with the constant voltage lines VL and the control electrodes Gd of the driver transistors DTFT. Hence, when the aforesaid issue of unfavorable display quality is resolved by means of the conductive pattern **140**, the aperture of the pixel array substrate **100** is not negatively affected to an excessive degree.

[0054] In the present embodiment, the constant voltage line VL is overlapped with the control electrode Gd of the driver transistor DTFT of the pixel unit **120**, so as to constitute a first storage capacitor CS1, which is shown in FIG. 5. One of the conductive lines **142** of the conductive pattern **140** is overlapped with the control electrode Gd of the driver transistor DTFT of the pixel unit **120**, so as to constitute a second storage capacitor CS2, which is shown in FIG. 5 as well. The first storage capacitor CS1 and the second storage capacitor CS2 share the same capacitor electrode (i.e., the control electrode Gd of the driver transistor DTFT), and another capacitor electrode (i.e., the constant voltage line VL) of the first storage capacitor CS1 and another capacitor electrode (i.e., the conductive line **142**) of the second storage capacitor CS2 have the same electrical potential. Therefore, the first storage capacitor CS1 and the second storage capacitor CS2 are connected in parallel to constitute a pixel storage capacitor of one of the pixel units **120**. That is, the pixel storage capacitance of the pixel unit **120** is obtained by adding the first storage capacitance and the second storage capacitance. Thereby, the conductive pattern **140** (i.e., the capacitor electrode of the second storage capacitor) not only can resolve said issue of unfavorable display quality but also can increase the pixel storage capacitance of the pixel unit **120**, such that the pixel array substrate **100** may have the improved performance.

[0055] FIG. 5 is a schematic cross-sectional diagram illustrating a pixel array substrate according to a first embodiment of the invention. Particularly, FIG. 5 corresponds to the sectional lines A-A', B-B' C-C', and D-D' depicted in FIG. 2. The relationship of the components in the pixel array will be elaborated hereinafter with reference to FIG. 2 and FIG. 5.

[0056] As shown in FIG. 2 and FIG. 5, in the present embodiment, the control electrodes Gd of the driver transistors DTFT, the control electrodes Gs of the switch transistors STFT, and the scan lines SL may be located in the same film layer. The pixel array substrate **100** described herein further includes an insulation layer GI (GI1) (shown in FIG. 5) that covers the control electrodes Gd and Gs and the scan lines SL. The film layers where the control electrodes Gd are located are between the insulation layer GI (GI1) and the first substrate **110**. The driver transistors DTFT further include channels CHd that are overlapped with the control electrodes Gd. The switch transistors STFT further include channels CHs that are overlapped with the control electrodes Gs. The channels CHd of the driver transistors DTFT and the channels CHs of the switch transistors STFT may be located in the same film layer. The insulation layer GI (GI1) may be located between the film layers where the channels CHd are located and the film layers where the control electrodes Gd are located.

[0057] In the present embodiment, the input electrodes Id and the output electrodes Od of the driver transistors DTFT, the input electrodes Is and the output electrodes Os of the

switch transistors STFT, the data lines DL, the constant voltage lines VL, and the constant voltage pad **132** may be located in the same film layer. The film layer where the channels CHd of the driver transistors DTFT are located is between the insulation layer GI1 and the film layer where the input electrodes Id of the driver transistors DTFT are located. However, the invention is not limited thereto, and the constant voltage pad **132** and the control electrodes Gd of the driver transistors DTFT or other components may be in the same film layer according to other embodiments of the invention.

[0058] The pixel array substrate **100** described herein further includes an insulation layer GI (GI2) (shown in FIG. 5) that covers the driver transistors DTFT, the switch transistors STFT, the data lines DL, and the constant voltage lines VL. The film layers where the input electrodes Id of the driver transistors DTFT are located are between the insulation layer GI (GI2) and the film layer where channels CHd are located. In each of the pixel regions **110a**, a portion of the insulation layer GI (GI2) has a plurality of openings H1 to H3. The opening H1 is filled with the conductive lines **142** of the conductive pattern **140**, such that the conductive lines **142** are in electrical contact with the constant voltage lines VL. The opening H2 is filled with the pixel electrode PE, such that the pixel electrode PE is in electrical contact with the output electrode Od of the driver transistor DTFT. In the peripheral region **110b**, a portion of the insulation layer GI (GI2) has the opening H3. The opening H3 is filled with the conductive frame **144** of the conductive pattern **140**, such that the conductive frame **144** is in electrical contact with the constant voltage pad **132** that outputs the constant voltage.

[0059] According to the present embodiment, the conductive pattern **140** is in the film layer different from the film layer where the output electrodes Od of the driver transistors DTFT, the input electrodes Id of the driver transistors DTFT, the control electrodes Gd of the driver transistors DTFT, and the pixel electrodes PE are located. Namely, the film layer where the insulation layer GI (GI2) is located may be between the film layer where the conductive pattern **140** is located and the film layers where the input electrodes Id of the driver transistors DTFT are located.

[0060] In the present embodiment, the pixel array substrate **100** further includes light-shielding patterns **146**. The light-shielding patterns **146** respectively shield the channels CHs of the switch transistors STFT and the channels CHd of the driver transistors DTFT. In the present embodiment, the conductive frame **140** and the light-shielding patterns **146** may be located in the same film layer. As shown in FIG. 5, the light-shielding patterns **146** may shield the light beam L on top of the pixel electrode PE. That is, when the pixel array substrate **100** is a part of the OLED display, the light-shielding patterns **146** may shield the light beam from the OLED layer, and thereby the OLED display having the pixel array substrate **100** may have the improved performance.

[0061] The pixel array substrate **100** described herein further includes an insulation layer GI (GI3) that covers the conductive pattern **140** and the light-shielding patterns **146**. The film layer where the conductive pattern **140** is located is between the insulation layer GI (GI3) and the insulation layer GI (GI2). The insulation layer GI (GI3) is located between the film layers where the pixel electrodes PE are located and the film layer where the conductive pattern **140** is located. The openings H2 and H4 of the insulation layers GI (GI2) and GI (GI3) are filled with the pixel electrodes PE, such that the

pixel electrodes PE are in electrical contact with the output electrodes Od of the driver transistors DTFT.

[0062] In the present embodiment, the film layer where the control electrodes Gd of the driver transistors DTFT is located are between the first substrate **110** and the film layer where the input electrodes Id of the driver transistors DTFT are located, and the film layer where the input electrodes Id of the driver transistors DTFT are located is between the film layer where the conductive pattern **140** is located and the film layer where the control electrodes Gd of the driver transistors DTFT are located. That is, the driver transistors DTFT described herein may be bottom-gate transistors. In the present embodiment, the film layers where the components of the switch transistors STFT are located are the same as the film layers where the components of the driver transistors DTFT are located, and the switch transistors STFT described herein may be bottom-gate transistors as well. However, the invention is not limited thereto, and the driver transistors DTFT and the switch transistors STFT in other embodiments of the invention may be in another form.

[0063] FIG. 6 is a schematic cross-sectional diagram illustrating an OLED display according to the first embodiment of the invention. With reference to FIG. 6, the OLED display **1000** includes the pixel array substrate **100**, a second substrate **200** opposite to the first substrate **110**, an OLED layer OLED located between the pixel electrodes PE and the second substrate **200**, and a common electrode layer **300** located between the second substrate **200** and the OLED layer OLED. Since the OLED display **1000** employs the pixel array substrate **100**, the OLED display **1000** is also able to resolve the conventional issue of unfavorable display quality caused by the significant difference in resistances between the input electrodes of the driver transistors and the constant voltage source.

Second Embodiment

[0064] FIG. 7 is a schematic diagram illustrating a pixel array substrate according to a second embodiment of the invention. With reference to FIG. 7, the pixel array substrate **100'** described in the present embodiment is similar to the pixel array substrate **100** described in the first embodiment, and thus the same and corresponding components of the two pixel array substrates **100** and **100'** are represented by the same or corresponding reference numbers. The difference between the pixel array substrate **100'** and the pixel array substrate **100** lies in that the types of the driver transistors DTFT' and the switch transistors STFT' of the pixel array substrate **100'** are different from those of the driver transistors DTFT and the switch transistors STFT of the pixel array substrate **100**, and the relative relationship between the conductive pattern **140'** and other film layers is also different from that between the conductive pattern **140** and other film layers. Said difference will be demonstrated below, while the similarity will not be further described.

[0065] With reference to FIG. 7, similar to the pixel array substrate **100** described in the first embodiment, the pixel array substrate **100'** described herein includes a first substrate **110'**, a plurality of pixel units **120'**, a plurality of data lines DL', a plurality of scan lines SL', a plurality of constant voltage lines VL', a constant voltage source **130'**, and a constant voltage pad **132'**. The first substrate **110'** has a plurality of pixel regions **110a'** arranged in an array and a peripheral region **110b'** surrounding the pixel regions **110a'**. The pixel units **120'** are located in the pixel regions **110a'**. Each of the pixel units

120 includes a switch transistor STFT, a driver transistor DTFT, and a pixel electrode PE. The switch transistor STFT has an input electrode Is, a control electrode Gs, and an output electrode Os; the driver transistor DTFT has an input electrode Id, a control electrode Gd, and an output electrode Od. The output electrode Os of the switch transistor STFT is electrically coupled to the control electrode Gd of the driver transistor DTFT. The pixel electrode PE is electrically coupled to the output electrode Od of the driver transistor DTFT. The data lines DL are located on the first substrate **110** and electrically coupled to the input electrodes Is of the switch transistors STFT. The scan lines SL are located on the first substrate **110**, interlaced with the data lines DL, and electrically coupled to the control electrodes Gs of the switch transistors STFT. The constant voltage lines VL are located on the first substrate **110** and electrically coupled to the input electrodes Id of the driver transistors DTFT. The constant voltage source **130** is located on the peripheral region **110b** of the first substrate **110** and provides a constant voltage to the constant voltage lines VL. The constant voltage pad **132** is located on the peripheral region **110b** of the first substrate **110** and outputs the constant voltage provided by the constant voltage source **130**.

[0066] The pixel array substrate **100'** also includes a conductive pattern **140'** located on the first substrate **110**. The conductive pattern **140'** includes a plurality of conductive lines **142'** interlaced with each other to form a net and located on the pixel regions **110a** and a conductive frame **144'** located in the peripheral region **110b**. The conductive frame **144'** surrounds and is electrically coupled to all of the conductive lines **142'**. The conductive frame **144'** is in electrical contact with the constant voltage pad **132** within the peripheral region **110b**. Each of the pixel regions **110a** is defined by two adjacent scan lines SL and two adjacent data lines DL. Besides, each of the pixel regions **110a** covers at least one of the pixel units **120** and a portion of at least one of the constant voltage lines VL. The covered portion of the at least one of the constant voltage lines VL located completely within each of the pixel regions **110a** is in electrical contact with at least one of the conductive lines **142'** within the pixel region **110a**.

[0067] FIG. 8 is a schematic diagram illustrating one of the pixel regions and a portion of the peripheral region in the pixel array substrate according to the second embodiment of the invention. The pixel region **110a** shown in FIG. 8 corresponds to the pixel region **110a** surrounded by dotted lines in FIG. 7, and the portion of the peripheral region **110b'** shown in FIG. 8 corresponds to the peripheral region **110b'** surrounded by dotted lines in FIG. 1. FIG. 9 illustrates film layers other than the film layer where the conductive pattern depicted in FIG. 8 is located. FIG. 10 illustrates the film layer where the conductive pattern depicted in FIG. 8 is located. FIG. 11 is a schematic cross-sectional diagram illustrating a pixel array substrate according to a second embodiment of the invention. Particularly, FIG. 11 corresponds to the sectional lines A-A', B-B' C-C', and D-D' depicted in FIG. 8. Note that FIG. 7 serves to explain the electrical connection among the components in the pixel array substrate, while the detailed structures of these components in the pixel array substrate are shown in FIG. 8, FIG. 9, and FIG. 10. The structures of these components in the pixel array will be elaborated hereinafter with reference to FIG. 8, FIG. 9, FIG. 10, and FIG. 11.

[0068] The difference between the first embodiment and the present embodiment lies in that the film layer where the conductive pattern **140'** is located is between the first sub-

strate **110** and the film layer where the input electrodes Id of the driver transistors DTFT' are located, and the film layer where the input electrodes Id of the driver transistors DTFT' are located is between the film layer where the conductive pattern **140'** is located and the film layer where the control electrodes Gd of the driver transistors DTFT' are located. That is, the driver transistors DTFT' described herein may be top-gate transistors. In the present embodiment, the film layers where the components of the switch transistors STFT' are located are the same as the film layers where the components of the driver transistors DTFT' are located, and the switch transistors STFT' described herein may be top-gate transistors as well.

[0069] FIG. 12 is a schematic cross-sectional diagram illustrating an OLED display according to the second embodiment of the invention. With reference to FIG. 12, the OLED display **1000'** includes the pixel array substrate **100'**, a second substrate **200** opposite to the first substrate **110**, an OLED layer OLED located between the pixel electrodes PE and the second substrate **200**, and a common electrode layer **300** located between the second substrate **200** and the OLED layer OLED. Since the effects and advantages of the OLED display **1000'** and the pixel array substrate **100'** are similar to those of the OLED display **1000** and the pixel array substrate **100**, no further description is provided hereinafter.

Third Embodiment

[0070] FIG. 13 is a schematic diagram illustrating a pixel array substrate according to a third embodiment of the invention. FIG. 14 is a schematic diagram illustrating one of the pixel regions and a portion of the peripheral region in the pixel array substrate according to the third embodiment of the invention. The pixel region **110a** shown in FIG. 14 corresponds to the pixel region **110a** surrounded by dotted lines in FIG. 13, and the portion of the peripheral region **110b'** shown in FIG. 14 corresponds to the peripheral region **110b'** surrounded by dotted lines in FIG. 13. FIG. 15 illustrates film layers other than the film layer where the conductive pattern depicted in FIG. 14 is located. FIG. 16 illustrates the film layer where the conductive pattern depicted in FIG. 14 is located. FIG. 17 is a schematic cross-sectional diagram illustrating a pixel array substrate according to a third embodiment of the invention. Particularly, FIG. 17 corresponds to the sectional lines A-A', B-B' C-C', and D-D' depicted in FIG. 14. Note that FIG. 13 serves to explain the electrical connection among the components in the pixel array substrate, while the detailed structures of these components in the pixel array substrate are shown in FIG. 14, FIG. 15, FIG. 16, and FIG. 17.

[0071] With reference to FIG. 13, FIG. 14, FIG. 15, FIG. 16, and FIG. 17, the pixel array substrate **100A** described in the present embodiment is similar to the pixel array substrate **100** described in the first embodiment, and thus the same and corresponding components of the two pixel array substrates **100** and **100A** are represented by the same or corresponding reference numbers. The difference between the two pixel array substrates **100** and **100A** lies in that the conductive pattern **140A** is electrically insulated from the constant voltage lines VL in the pixel array substrate **100A**. Said difference will be demonstrated below, while the similarity will not be further described.

[0072] The pixel array substrate **100A** described in the present embodiment includes a first substrate **110**, a plurality of pixel units **120** located on the first substrate **110**, a plurality of data lines DL located on the first substrate **110**, a plurality

of scan lines SL located on the first substrate **110** and interlaced with the data lines DL, a plurality of constant voltage lines VL located on the first substrate **110** and interlaced with the scan lines SL, a constant voltage source **130** located on the peripheral region **110b** of the first substrate **110**, and the conductive pattern **140A**. The constant voltage source **130** provides a constant voltage to the constant voltage lines VL.

[0073] The first substrate **110** has a plurality of pixel regions **110a** arranged in an array and a peripheral region **110b** surrounding the pixel regions **110a**. The pixel units **120** are located in the pixel regions **110a**. Each of the pixel regions **110a** is defined by two adjacent scan lines SL and two adjacent data lines DL interlaced with the two scan lines SL. The pixel units **120** are located in the pixel regions **110a**. Each of the pixel regions **110a** includes at least one of the pixel units **120**. Each of the pixel units **120** includes a switch transistor STFT, a driver transistor DTFT, and a pixel electrode PE. The switch transistor STFT has an input electrode Is, a control electrode Gs, and an output electrode Os; the driver transistor DTFT has an input electrode Id, a control electrode Gd, and an output electrode Od. The output electrode Os of the switch transistor STFT is electrically coupled to the control electrode Gd of the driver transistor DTFT. The pixel electrode PE is electrically coupled to the output electrode Od of the driver transistor DTFT. The data lines DL are electrically coupled to the input electrodes Is of the switch transistors STFT. The scan lines SL are electrically coupled to the control electrodes Gs of the switch transistors STFT. The constant voltage lines VL are electrically coupled to the input electrodes Id of the driver transistors DTFT.

[0074] The conductive pattern **140A** is similar to the conductive pattern **140** described in the first embodiment. Specifically, from the direction perpendicular to the first substrate **110**, it can be observed that the relative positions of the conductive pattern **140A** and other components of the pixel array substrate **100A** are the same as those of the conductive pattern **140** and other components of the pixel array substrate **100**. The film layers where the conductive pattern **140A** and other components of the pixel array substrate **100A** are located and the film layers where the conductive pattern **140** and other components of the pixel array substrate **100** are located are arranged in the same order. The difference between the conductive pattern **140A** and the conductive pattern **140** lies in that the conductive pattern **140A** is not in electrical contact with the constant voltage lines VL, while the conductive pattern **140** is in electrical contact with the constant voltage lines VL. Specifically, the conductive pattern **140A** also includes a plurality of conductive lines **142A** and a conductive frame **144A**. The difference between the conductive frame **144A** described in the present embodiment and the conductive frame **144** described in the first embodiment lies in that the conductive frame **144A** is not electrically connected to the constant voltage lines VL nor electrically connected to the constant voltage source **130**. The difference between the conductive lines **142A** described in the present embodiment and the conductive lines **142** described in the first embodiment lies in that the conductive lines **142A** are not electrically connected to the constant voltage lines VL nor electrically connected to the constant voltage source **130**.

[0075] FIG. **18** is a schematic cross-sectional diagram illustrating an OLED display according to the third embodiment of the invention. With reference to FIG. **18**, the OLED display **1000A** includes the pixel array substrate **100A** depicted in FIG. **17**, a second substrate **200** opposite to the first substrate

110, an OLED layer OLED located between the pixel electrodes PE and the second substrate **200**, and a common electrode layer **300A** located between the second substrate **200** and the OLED layer OLED.

[0076] The common electrode layer **300A** is overlapped with the control electrodes Gd of the driver transistors DTFT. The film layer where the control electrode Gd of each of the driver transistors DTFT is located is between the first substrate **110** and the film layer where the input electrode Id of each of the driver transistors DTFT is located. The film layer where the input electrode Id of each driver transistor DTFT is located is between a film layer where the conductive pattern **140A** is located and the film layer where the control electrode Gd of each driver transistor DTFT is located. The film layer where the conductive pattern **140A** is located is between the OLED layer OLED and the film layer where the input electrode Id of each driver transistor DTFT is located.

[0077] It should be mentioned that the conductive pattern **140A** is in electrical contact with the common electrode layer **300A**. The common electrode layer **300A** is overlapped with the control electrode Gd of the driver transistor DTFT of one of the pixel units **120** to constitute a first storage capacitor. A portion of the conductive pattern **140A** is overlapped with the control electrode Gd of the driver transistor DTFT of one of the pixel units **120** (shown in FIG. **14**), so as to constitute a second storage capacitor. The first storage capacitor and the second storage capacitor share the same capacitor electrode (i.e., the control electrode Gd of the driver transistor DTFT), and another capacitor electrode (i.e., the common electrode layer **300**) of the first storage capacitor CS1 and another capacitor electrode (i.e., the conductive pattern **140A**) of the second storage capacitor have the same electrical potential. Therefore, the first storage capacitor and the second storage capacitor are connected in parallel to constitute a pixel storage capacitor of one of the pixel units **120**. That is, the pixel storage capacitance of the pixel unit **120** is obtained by adding the first storage capacitance and the second storage capacitance. Due to the conductive pattern **140A** (i.e., the capacitor electrode of the second storage capacitor), the pixel storage capacitance of the pixel unit **120** can be enhanced, and thus the OLED display **1000A** may achieve favorable display effects. To be specific, the distance from the conductive pattern **140A** to the control electrode Gd is less than the distance from the common electrode layer **300A** to the control electrode Gd; therefore, the second storage capacitance generated by the conductive pattern **140A** may be greater than the first storage capacitance generated by the common electrode layer **300A**, and thus the pixel storage capacitance is significantly increased. As a result, the conventional issue of insufficient pixel storage capacitance caused by the excessively large distance from the common electrode layer to the control electrode Gd can be better resolved.

[0078] To sum up, in the OLED display and the pixel array substrate of the OLED display described in an embodiment of the invention, the net-shaped conductive pattern lessens the difference in resistances between the constant voltage source and the input electrodes of the driver transistors distributed onto the first substrate, and thereby the constant voltage respectively transmitted into the input electrode of each driver transistor does not vary significantly. Thereby, the conventional issue of unfavorable display quality caused by the significant difference in resistances between the input electrodes of the driver transistors and the constant voltage source can be better resolved.

[0079] Besides, in the OLED display provided in another embodiment of the invention, through the conductive pattern that is in electrical contact with the common electrode and is overlapped with the control electrode of each pixel unit, the pixel storage capacitance of each pixel unit may increase, and thus the OLED display is able to accomplish favorable display effects.

[0080] Although the invention has been described with reference to the above exemplary embodiments, it will be apparent to one of ordinary skill in the art that modifications to the described exemplary embodiments may be made without departing from the spirit of the invention. Accordingly, the scope of the invention will be defined by the attached claims and not by the above detailed descriptions.

What is claimed is:

1. A pixel array substrate comprising:

a first substrate having a plurality of pixel regions arranged in an array and a peripheral region surrounding the pixel regions;

a plurality of pixel units located in the pixel regions, each of the pixel units comprising:

a switch transistor having an input electrode, a control electrode, and an output electrode;

a driver transistor having an input electrode, a control electrode, and an output electrode, wherein the output electrode of the switch transistor is electrically coupled to the control electrode of the driver transistor; and

a pixel electrode electrically coupled to the output electrode of the driver transistor;

a plurality of data lines located on the first substrate and electrically coupled to the input electrodes of the switch transistors;

a plurality of scan lines located on the first substrate, interlaced with the data lines, and electrically coupled to the control electrodes of the switch transistors;

a plurality of constant voltage lines located on the first substrate and electrically coupled to the input electrodes of the driver transistors;

a constant voltage source located on the peripheral region of the first substrate, the constant voltage source providing a constant voltage to the constant voltage lines;

a constant voltage pad located on the peripheral region of the first substrate, the constant voltage pad outputting the constant voltage; and

a conductive pattern located on the first substrate, the conductive pattern comprising:

a plurality of conductive lines interlaced with each other to form a net and located on the pixel regions of the first substrate; and

a conductive frame located on the peripheral region of the first substrate and surrounding and electrically coupled to the conductive lines, the conductive frame being in electrical contact with the constant voltage pad within the peripheral region, each of the pixel regions being defined by two adjacent scan lines of the scan lines and two adjacent data lines of the data lines, each of the pixel regions covering at least one of the pixel units and a portion of one of the constant voltage lines, the covered portion of the one of the constant voltage lines completely within the each of the pixel regions being in electrical contact with the one of the conductive lines of the conductive pattern.

2. The pixel array substrate as recited in claim 1, wherein the conductive lines of the conductive pattern and the constant voltage lines are overlapped.

3. The pixel array substrate as recited in claim 2, wherein the conductive lines are divided into a plurality of first conductive lines and a plurality of second conductive lines, the first conductive lines are parallel to extension directions of the constant voltage lines, the second conductive lines are interlaced with the first conductive lines, and the constant voltage lines cover the first conductive lines.

4. The pixel array substrate as recited in claim 3, wherein the second conductive lines are overlapped with the control electrodes of the driver transistors and the data lines.

5. The pixel array substrate as recited in claim 1, wherein the one of the constant voltage lines is overlapped with the control electrode of the driver transistor of the one of the pixel units to constitute a first storage capacitor, the one of the conductive lines is overlapped with the control electrode of the driver transistor of the one of the pixel units to constitute a second storage capacitor, and the first storage capacitor and the second storage capacitor are connected in parallel to constitute a pixel storage capacitor of the one of the pixel units.

6. The pixel array substrate as recited in claim 1, wherein the conductive pattern is in a film layer different from film layers where the output electrodes of the driver transistors, the input electrodes of the driver transistors, the control electrodes of the driver transistors, and the pixel electrodes are located.

7. The pixel array substrate as recited in claim 1, wherein a film layer where the control electrodes of the driver transistors is located are between the first substrate and a film layer where the input electrodes of the driver transistors are located, and the film layer where the input electrodes of the driver transistors are located is between a film layer where the conductive pattern is located and the film layer where the control electrodes of the driver transistors are located.

8. The pixel array substrate as recited in claim 1, wherein a film layer where the conductive pattern is located is between the first substrate and a film layer where the input electrodes of the driver transistors are located, and the film layer where the input electrodes of the driver transistors are located is between a film layer where the control electrodes of the driver transistors are located and the film layer where the conductive pattern is located.

9. The pixel array substrate as recited in claim 1, further comprising a plurality of light-shielding patterns respectively shielding a plurality of channels of the switch transistors and a plurality of channels of the driver transistors.

10. The pixel array substrate as claimed in claim 9, wherein the light-shielding patterns and the conductive pattern are located in the same film layer.

11. An organic light-emitting diode display comprising:

a pixel array substrate comprising:

a first substrate having a plurality of pixel regions arranged in an array and a peripheral region surrounding the pixel regions;

a plurality of pixel units located in the pixel regions, each of the pixel units comprising:

a switch transistor having an input electrode, a control electrode, and an output electrode;

a driver transistor having an input electrode, a control electrode, and an output electrode, wherein the output

- electrode of the switch transistor is electrically coupled to the control electrode of the driver transistor; and
 - a pixel electrode electrically coupled to the output electrode of the driver transistor;
 - a plurality of data lines located on the first substrate and electrically coupled to the input electrodes of the switch transistors;
 - a plurality of scan lines located on the first substrate, interlaced with the data lines, and electrically coupled to the control electrodes of the switch transistors;
 - a plurality of constant voltage lines located on the first substrate and electrically coupled to the input electrodes of the driver transistors;
 - a constant voltage source located on the peripheral region of the first substrate, the constant voltage source providing a constant voltage to the constant voltage lines;
 - a constant voltage pad located on the peripheral region of the first substrate, the constant voltage pad outputting the constant voltage; and
 - a conductive pattern located on the first substrate, the conductive pattern comprising:
 - a plurality of conductive lines interlaced with each other to form a net and located on the pixel regions of the first substrate; and
 - a conductive frame located on the peripheral region of the first substrate and surrounding and electrically coupled to the conductive lines, the conductive frame being in electrical contact with the constant voltage pad within the peripheral region, each of the pixel regions being defined by two adjacent scan lines of the scan lines and two adjacent data lines of the data lines, each of the pixel regions covering at least one of the pixel units and a portion of one of the constant voltage lines, the covered portion of the one of the constant voltage lines completely within the each of the pixel regions being in electrical contact with the one of the conductive lines of the conductive pattern;
 - a second substrate opposite to the first substrate;
 - an organic light-emitting diode layer located between the second substrate and the pixel electrodes; and
 - a common electrode layer located between the second substrate and the organic light-emitting diode layer.
- 12.** An organic light-emitting diode display comprising:
- a pixel array substrate comprising:
 - a first substrate having a plurality of pixel regions arranged in an array and a peripheral region surrounding the pixel regions;
 - a plurality of pixel units located in the pixel regions, each of the pixel units comprising:
 - a switch transistor having an input electrode, a control electrode, and an output electrode;
 - a driver transistor having an input electrode, a control electrode, and an output electrode, wherein the output electrode of the switch transistor is electrically coupled to the control electrode of the driver transistor; and
 - a pixel electrode electrically coupled to the output electrode of the driver transistor;
 - a plurality of data lines located on the first substrate and electrically coupled to the input electrodes of the switch transistors;
 - a plurality of scan lines located on the first substrate and electrically coupled to the control electrodes of the switch transistors;
 - a plurality of constant voltage lines located on the first substrate and electrically coupled to the input electrodes of the driver transistors;
 - a constant voltage source located on the peripheral region of the first substrate, the constant voltage source providing a constant voltage to the constant voltage lines;
 - a constant voltage pad located on the peripheral region of the first substrate, the constant voltage pad outputting the constant voltage; and
 - a conductive pattern located on the first substrate, the conductive pattern comprising:
 - a plurality of conductive lines interlaced with each other to form a net and located on the pixel regions of the first substrate; and
 - a conductive frame located on the peripheral region of the first substrate and surrounding and electrically coupled to the conductive lines, the conductive frame being in electrical contact with the constant voltage pad within the peripheral region, each of the pixel regions being defined by two adjacent scan lines of the scan lines and two adjacent data lines of the data lines, each of the pixel regions covering at least one of the pixel units and a portion of one of the constant voltage lines, the covered portion of the one of the constant voltage lines completely within the each of the pixel regions being in electrical contact with the one of the conductive lines of the conductive pattern;
 - a second substrate opposite to the first substrate;
 - an organic light-emitting diode layer located between the second substrate and the pixel electrodes; and
 - a common electrode layer located between the second substrate and the organic light-emitting diode layer.
- 13.** The organic light-emitting diode display as recited in claim **12**, wherein the common electrode layer is overlapped with the control electrode of the driver transistor of one of the pixel units to constitute a first storage capacitor, a portion of the conductive pattern is overlapped with the control electrode of the driver transistor of one of the pixel units to constitute a second storage capacitor, and the first storage capacitor and the second storage capacitor are connected in parallel to constitute a pixel storage capacitor of one of the pixel units.
- 14.** The organic light-emitting diode display as recited in claim **12**, wherein the conductive pattern comprises:
- a plurality of conductive lines interlaced with each other to form a net and located above the pixel regions of the first substrate; and
 - a conductive frame located above the peripheral region of the first substrate, the conductive frame surrounding and being electrically coupled to the conductive lines.
- 15.** The organic light-emitting diode display as recited in claim **14**, wherein the conductive lines of the conductive pattern and the constant voltage lines are overlapped.
- 16.** The organic light-emitting diode display as recited in claim **15**, wherein the conductive lines are divided into a plurality of first conductive lines and a plurality of second conductive lines, the first conductive lines are parallel to extension directions of the constant voltage lines, the second conductive lines are interlaced with the first conductive lines, and the constant voltage lines cover the first conductive lines.
- 17.** The organic light-emitting diode display as recited in claim **16**, wherein the second conductive lines are overlapped with the control electrodes of the driver transistors and the data lines.

18. The organic light-emitting diode display as recited in claim **12**, wherein the pixel array substrate further comprises a plurality of light-shielding patterns respectively shielding a plurality of channels of the switch transistors and a plurality of channels of the driver transistors.

19. The organic light-emitting diode display as recited in claim **18**, wherein the light-shielding patterns and the conductive pattern are located in the same film layer.

* * * * *

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摘要(译)

像素阵列基板包括第一基板，像素单元，数据线，扫描线，恒压线，恒压源，恒压垫和导电图案。第一基板具有像素区域和围绕像素区域的外围区域。导电图案包括彼此交错的导电线以形成网和围绕导电线并且电耦合到导电线的导电框架。导电框架与外围区域内的恒压垫电接触。每个像素区域由两条相邻的扫描线和两条相邻的数据线限定。完全位于每个像素区域内的一个恒压线的一部分与像素区域内的导线之一电接触。还提供了包括像素阵列基板和另一OLED的OLED显示器。

